## 10/560228 IAP9 Rec'd FCT/PTD 12 DFC 2008

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: Hiroshi ONO et al.

Serial Number: Not yet assigned

(§371 of international application No. PCT/JP2003/07554)

Filed: December 12, 2005

For: POLISHING SLURRY FOR METAL, AND POLISHING METHOD

Attorney Docket Number: 053460

Customer Number: 38834

December 12, 2005

## INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents

P. O. Box 1450

Alexandria, VA 22313-1450

Sir:

In compliance with 37 C.F.R. §1.56, Applicants direct the attention of the Patent and Trademark Office to the documents listed on the attached PTO/SB/08. A copy of each non-U.S. document is enclosed herewith.

If there are any fees due in connection with the filing of this paper, please charge Deposit Account No. 50-2866.

Respectfully submitted,

Westerman, Hatfori, Daniels & Adrian, LLP

Attorney for Applicants Registration No. 32,878 Felephone: (202) 822-110

Telephone: (202) 822-1100 Facsimile: (202) 822-1111

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Enclosure: PTO/SB/08, 10 documents and international search report.

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Combined Form PTO/SB/08A&B

Sheet

## INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(use as many sheets as necessary)

of

Complete if Known				
Application Number	New application			
Confirmation Number				
Filing Date	December 12, 2005			
First Named Inventor	Hiroshi ONO et al.			
Art Unit				
Examiner Name				
Attorney Docket Number	053460			

U.S. PATENT DOCUMENTS					
Examiner Initials*	Cite	Document Number		Publication Date	
	No.1	Number	Kind Code <sup>2</sup> (if known)	MM-DD-YYYY	Name of Patentee or Applicant of Cited Document
/MM/	1	US 4,944,836		07-31-1990	Kaus D. Beyer et al.
		US			

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FOREIGN PATENT DOCUMENTS							
Examiner Initials*	Cite No.1	Foreign Patent Document			Publication Date	Name of Patentee or	Translation <sup>6</sup>
		Country Code <sup>3</sup>	Number <sup>4</sup>	Kind Code <sup>5</sup> (if known)	MM-DD-YYYY	Applicant of Cited Document	I ranslation
/MM/	2	JP	2002-134442		05-10-2002	Hitachi Chem. Co., Ltd.	Abstract, cited in the ISR
/MM/	3	EPO	0 696 651 A1		02-14-1996	MEC Co., Ltd.	Yes, cited in the ISR
/MM/	4	EPO	1 260 607 A2		11-27-2002	Shipley Co., LLC	In English, cited in the ISR
/MM/	5	JP	11-172467		06-29-1999	Ebara Densan Ltd.	Abstract, cited in the ISR
/MM/	6	DE	199 26 117 A1		12-16-1999	Ebara Densan Ltd.	No, cited in the ISR
/MM/	7	JP	11-204942		07-30-1999	Hitachi Chem. Co., Ltd.	Abstract, cited in the ISR
/MM/	8	PCT	WO 00/13217		03-09-2000	Hitachi Chem. Co., Ltd.	Abstract, cited in the ISR
/MM/	9	JP	02-278822		11-15-1990	Int'l. Business Mach. (IBM)	Abstract, cited in the spec.
/MM/	10	JP	8-83780		03-26-1996	Toshiba Corp.	Abstract, cited in the spec.
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Examiner Initials*	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.	Translation <sup>6</sup>
/MM/	11	F. B. KAUFMAN et al.; "Chemical-Mechanical Polishing for Fabricating Patterned W Metal Features as Chip Interconnects;" Journal of the Electrochem. Society, Vol. 138, No. 11, November 1991, pp. 3460-3465. Cited in the specification.	

Examiner Signature	/Michael Marcheschi/ (07/24/2008)	Date Considered				
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in						
conformance and not considered. Include copy of this form with next communication to applicant.						

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